Docket Number (Ontional) Form PTO-1449 ENFORMATION DISCLOSURE CITATION 068758.0102 09/786,022 IN AN APPLICATION (Use several sheets if necessary) Applicant Deboy et al. Filing Date 04/22/99 Group Art Unit: U.S. PATENT DOCUMENTS SUB-FILING DATE IF DATE CLASS **EXAMINER** DOCUMENT NAME NUMBER CLASS APPROPRIATE INITIAL 317 234 10/19/60 02/23/65 Denkewalter et al. 3,171,068 3,925,803 12/09/75 Kobayashi 357 22 07/12/73 357 50 10/31/74 06/01/76 Okuhura et al. 3,961,356 52 11/01/74 01/11/77 Matsushita et al. 357 4,003,072 29 571 12/13/76 4,055,884 11/01/77 Jambotkar 357 23 04/22/77 4,072,975 02/07/78 Ishtiani 07/18/78 357 23 03/09/77 Tihanyi 4,101,922 357 23 08/08/77 03/20/79 Jambotkar 4,145,700 05/03/79 4,320,410 03/16/82 Nishizawa et al. 357 43 23 08/17/82 Blanchard 357 04/14/80 4,345,265 357 23 08/06/79 12/28/82 Goodman et al 4,366,495 357 23 02/09/81 03/08/83 Lidow et al. 4,376,286 Translation SUR-**COUNTRY CLASS** DOCUMENT DATE **CLASS** NUMBER YES NO EP 0 053 854 B1 16.06.82 **EPO** HOIL 29/06 HOIL 29/78 UK 16.02.82 GB 2 089 118 A HOIL 29/78 EP 0 069 429 A2 12.01.83 **EPO** HOIL 29/784 01.04.92 EPO EP 0 447 873 A2 HOIL 29/784 25.03.93 DE 43 09 764 A1 Germany HOIL 29/78 29.9.94 DE 43 09 764 C2 Germany OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.) 1967 A.S. Grove: "Physics and Technology of Semiconductor Devices" p 78-83 1976 B. Jayant Baliga, Sorab K. Ghandi: "Analytical Solutions for the Breakdown Voltage of Abrupt Cylindrical and Spherical Junctions" (p 739-744) 1977 Richard F. David: "Computerized Thermal Analysis of Hybrid Circuits" 27th Electronics Components Conference, May 16-18 1977 (p 324-332) DATE CONSIDERED EXAMINER EXAMINER: Initial if castion considered, whether or not cristion is in conformance with APEP \$609; Draw line through cristion if not in conformance and not considered. Include copy of this form with next

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